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PATENT & TRADEMARK OFFICE

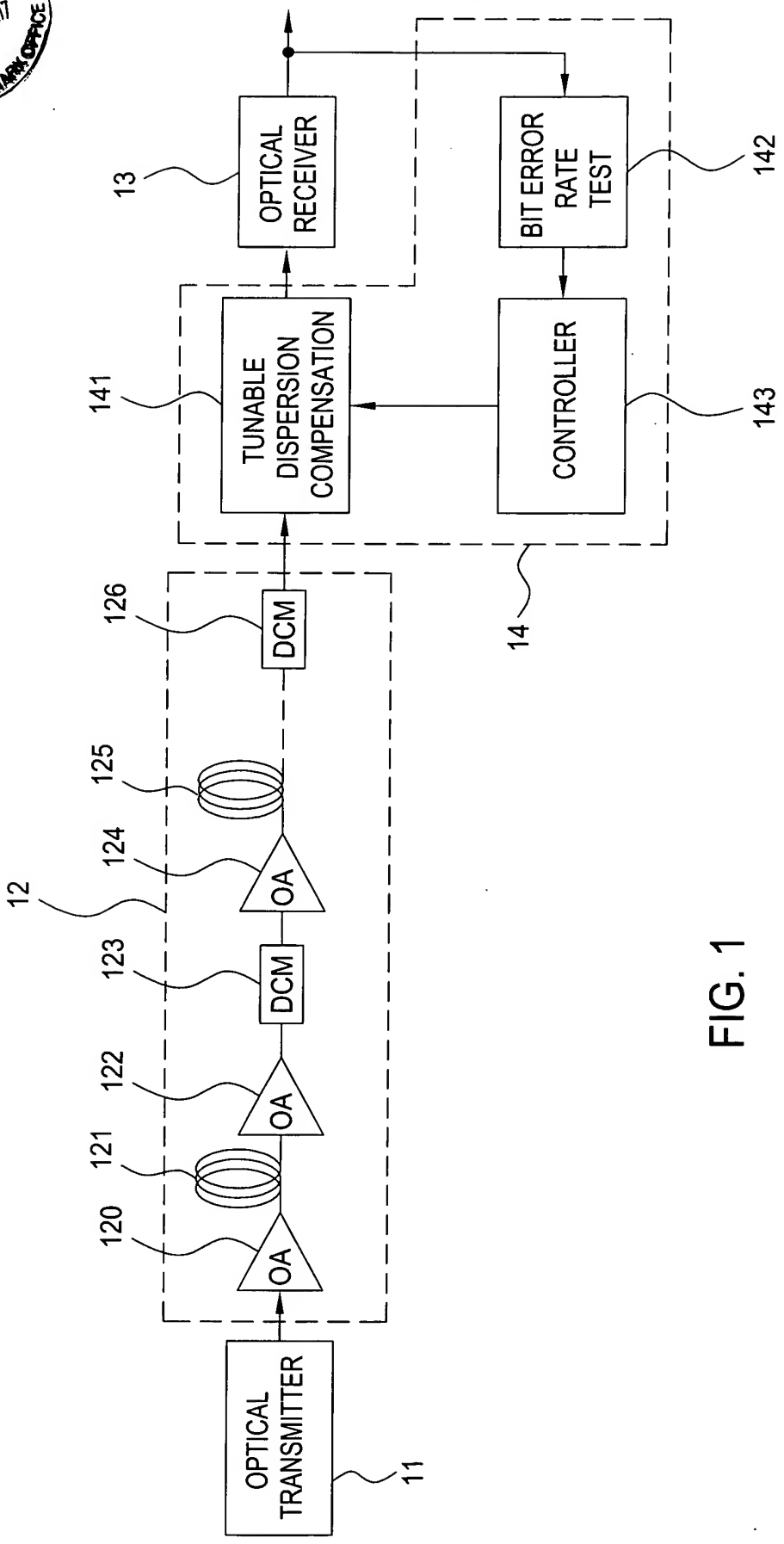

FIG. 1

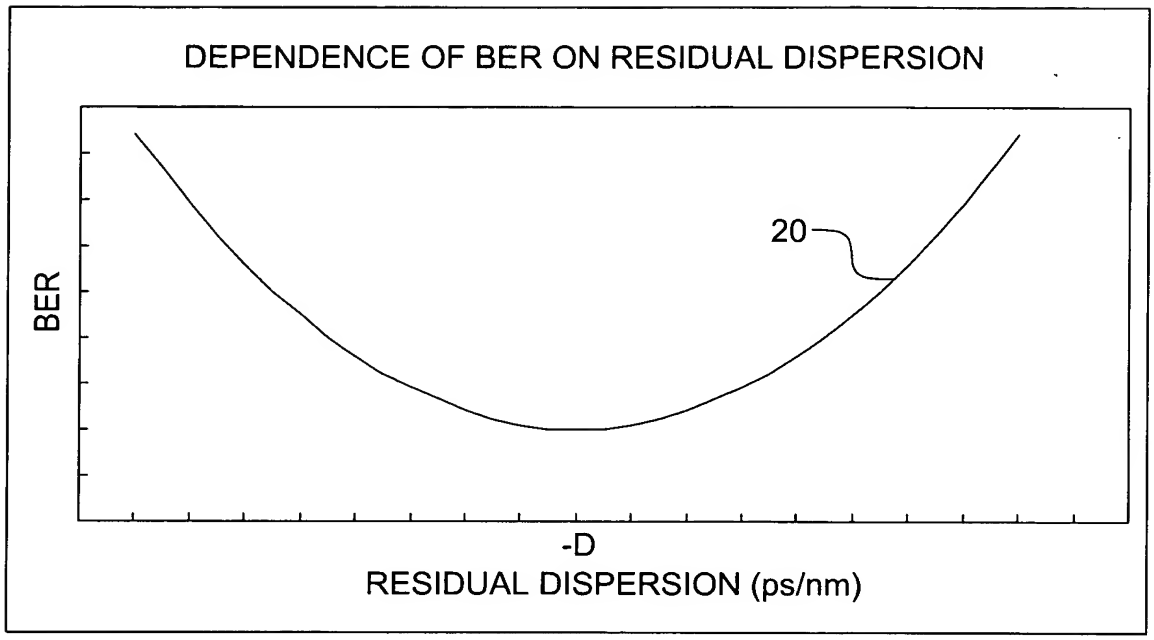
DEPENDENCE OF BER ON RESIDUAL DISPERSION
BER
20
-D
RESIDUAL DISPERSION (ps/nm)

FIG. 2